

## SEARCHED

Class	Sub.	Date	Exmr.
257	192 194 195	11-7	DMC
438	192		
257	192 194 195	9-11	nm
438	192		
438	above updated 167 285 590	01-28 S	nm S
	above updated	5-6	nm
	above updated	10-3	DMC

## INTERFERENCE SEARCHED

Class	Sub.	Date	Exmr.

## SEARCH NOTES (INCLUDING SEARCH STRATEGY)

East Search	Date	Exmr.
US PAT, JPO, ZPO Den 257/192, 194, 195	11-7	DMC
Text Search HEMT & Schottky + (resistive layer or resistance layer)		
Consulted with Tom Thomas Stone Lake	4-25	DMC
Inventor Search <u>NPL</u> IEEE capsule	9-11	DMC
Consulted with Stone Lake	1-28	DMC

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